LISTING OF THE CLAIMS

This listing of claims will replace all prior versions, and listings, of claims in the application:

1. (Currently Amended) An optical element consisting of:

a transparent insulating substrate;

a circuitry layer on the insulating substrate, said circuitry layer including an active polysilicon layer;

a plurality of pixels; and

an opaque optical shielding layer disposed to lie between the insulating substrate layer and the active polysilicon layer; wherein the opaque shielding layer shields the polysilicon layer from light incident upon the insulating substrate layer and functions to block the incident light from leaking between adjacent pixels; wherein the optical element does not include a shield above the circuitry layer that functions to block the incident light from leaking between adjacent pixels; and wherein the optical element is part of a liquid crystal display and the opaque shielding layer also functions as a black matrix for said display.

Claim 2 (Canceled).

3. (Original) The optical element of claim 1 wherein the shielding layer comprises a material that is unaffected by exposure to temperatures up to 1,100°C.

Claims 4-23 (Canceled).

24. (*Previously Presented*) The optical element of claim 1, wherein the optical shielding layer is comprised of a light reflective material.

Claim 25 (Canceled).

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- 26. (*Currently Amended*) The optical element of claim 1, wherein the optical shielding layer is comprised <u>either</u> of <u>one of</u> silicon nitride, layers of silicon oxide and silicon nitride, <u>and or</u> a refractory metal encapsulated in a suitable barrier layer.
- 27. (*Currently Amended*) The optical element of claim 26, wherein the refractory metal comprises one of either tungsten, cobalt, and or titanium.
- 28. (*Currently Amended*) The optical element of claim 26, wherein the barrier layer comprises one of either tungsten silicide, tungsten nitride, and or titanium nitride.
- 29. (*Previously Presented*) The optical element of claim 26, further comprising a cap over said barrier layer.
- 30. (*Currently Amended*) The optical element of claim 26, wherein the cap comprises one of either silicon oxide, silicon nitride, and or silicon oxynitride.
- 31. (*Previously Presented*) The optical element of claim 26, further comprising an adhesive layer disposed between the refractory metal and the transparent insulating substrate.
- 32. (*Previously Presented*) The optical element of claim 31, wherein the adhesive is comprised of a titanium/titanium nitride laminate.